

Developments towards a transversal electron target for CRYRING

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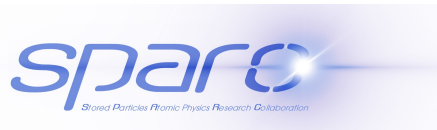
for the SPARC working group “Electron Targets“,
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Bundesministerium
für Bildung
und Forschung

Justus-Liebig-University Giessen/GSI Darmstadt

19th of September 2016, SPARC Workshop, Kraków

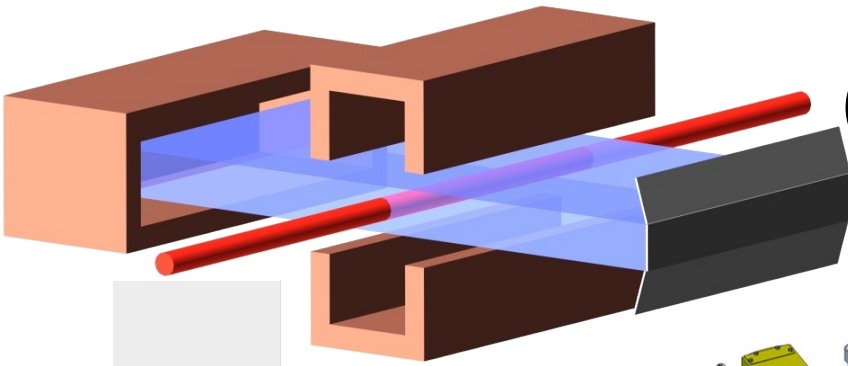


Outline

- Concept and Physics Case
- Tests with a Multi-Electrode Target Optimized for the Giessen Low-Energy Single-Pass Setup
- Status and Outlook

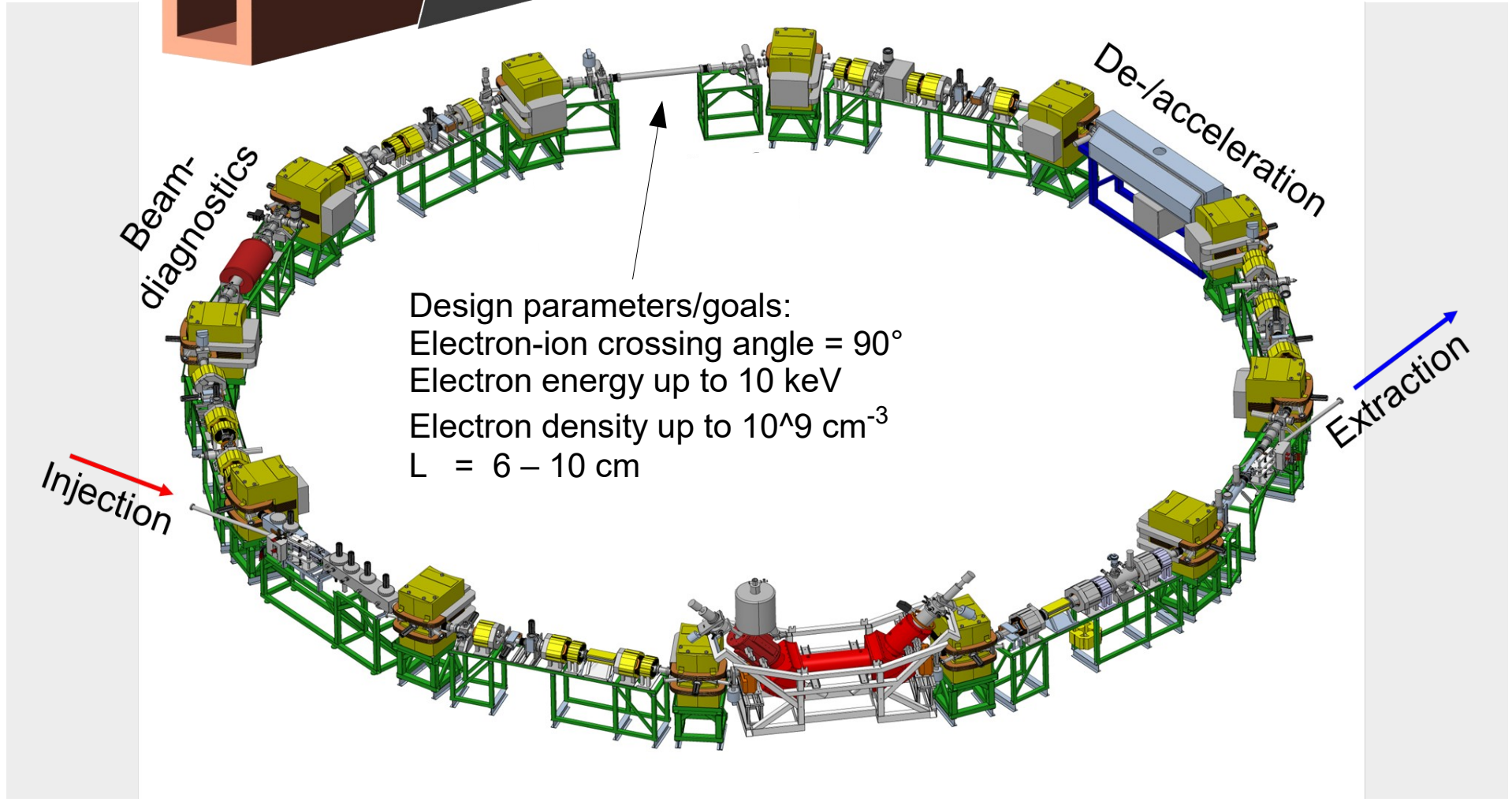
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Concept

Transversal target with electron beam formed like a **sheet/ribbon**

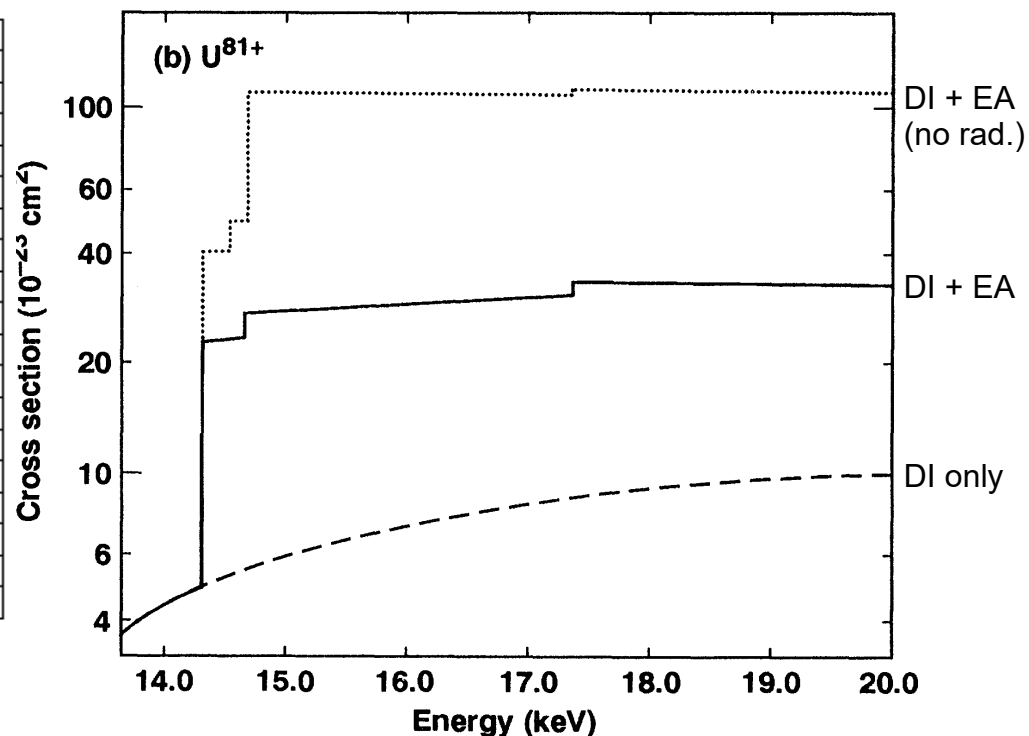
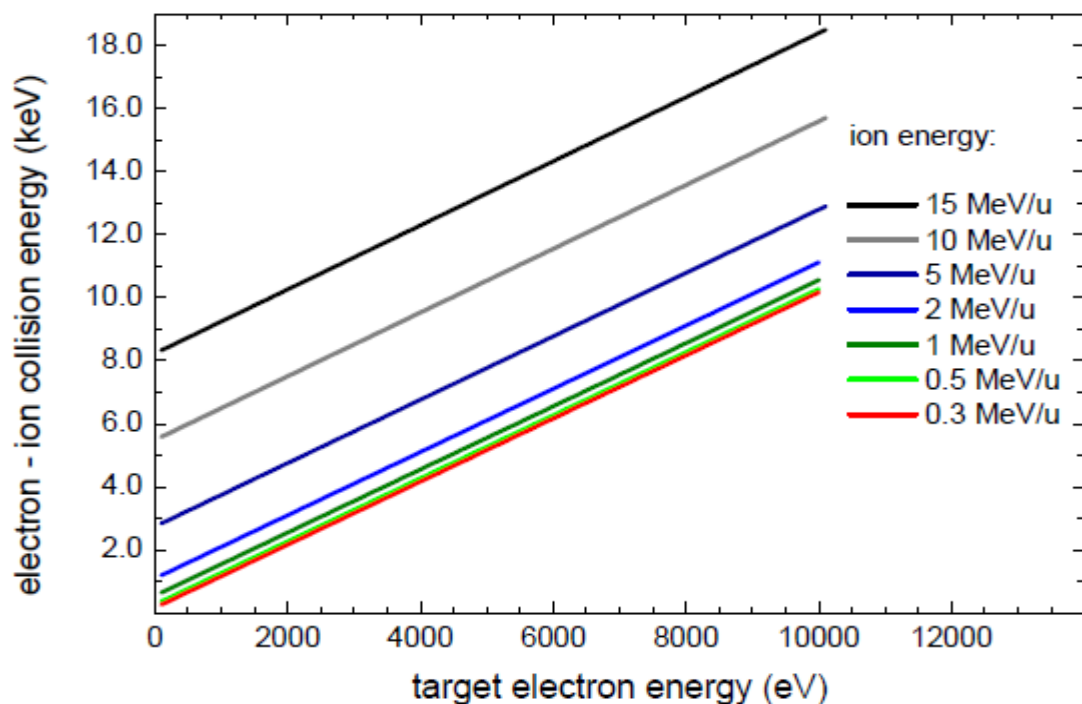


Design parameters/goals:
Electron-ion crossing angle = 90°
Electron energy up to 10 keV
Electron density up to 10^9 cm^{-3}
 $L = 6 - 10 \text{ cm}$

Physics Case

- Main advantages:
 - Free electrons (no target nucleus)
 - High energy resolution, no NRC, no excitations due to the nucleus
 - Well localized interaction region
 - Spectroscopy with large solid angles
 - Easy and precise tunable collision energy
- Possible experiments:
 - Photon spectroscopy (REC) at low ion energies
 - Electron-impact excitation (EIE) and ionization (EII)
 - Indirect and/or resonant contributions
 - 2nd generation: Nuclear excitation by electron capture (NEEC) and resonant electron scattering (RES)

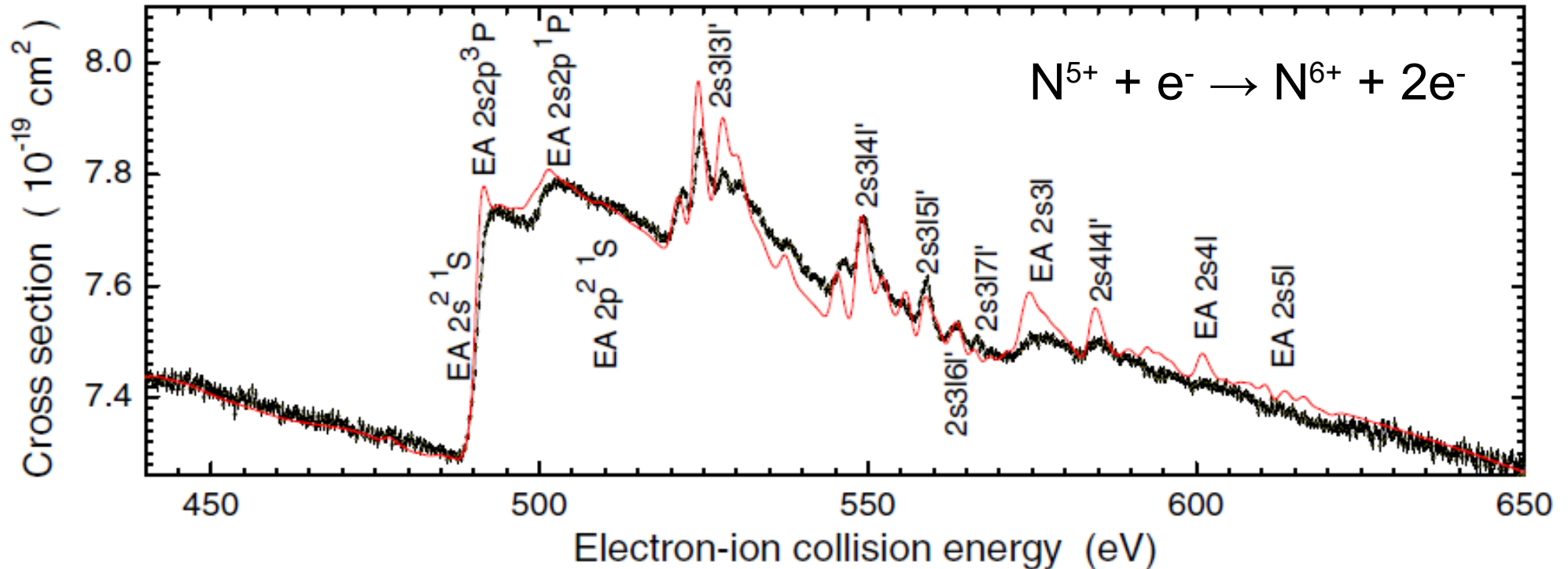
Physics Case Example: EII of HCI



Distorted-wave calculations from
Reed, Chen and Moores, Phys. Rev. A
44, 4336 (1991)

- Investigation of heavy and highly charged ions, e.g. U^{81+}
- Will importance of indirect processes (such as EA, log-scale for U^{81+}) increase further?

Example From the Giessen Single-Pass Setup: EII of N^{5+}



A. Müller et al., PRA **90** (2014) 010701(R).

- High-resolution cross section measurements with fine-step energy-scan method
- Measurement of accurate absolute cross sections (Giessen: $\sim 6\%$)

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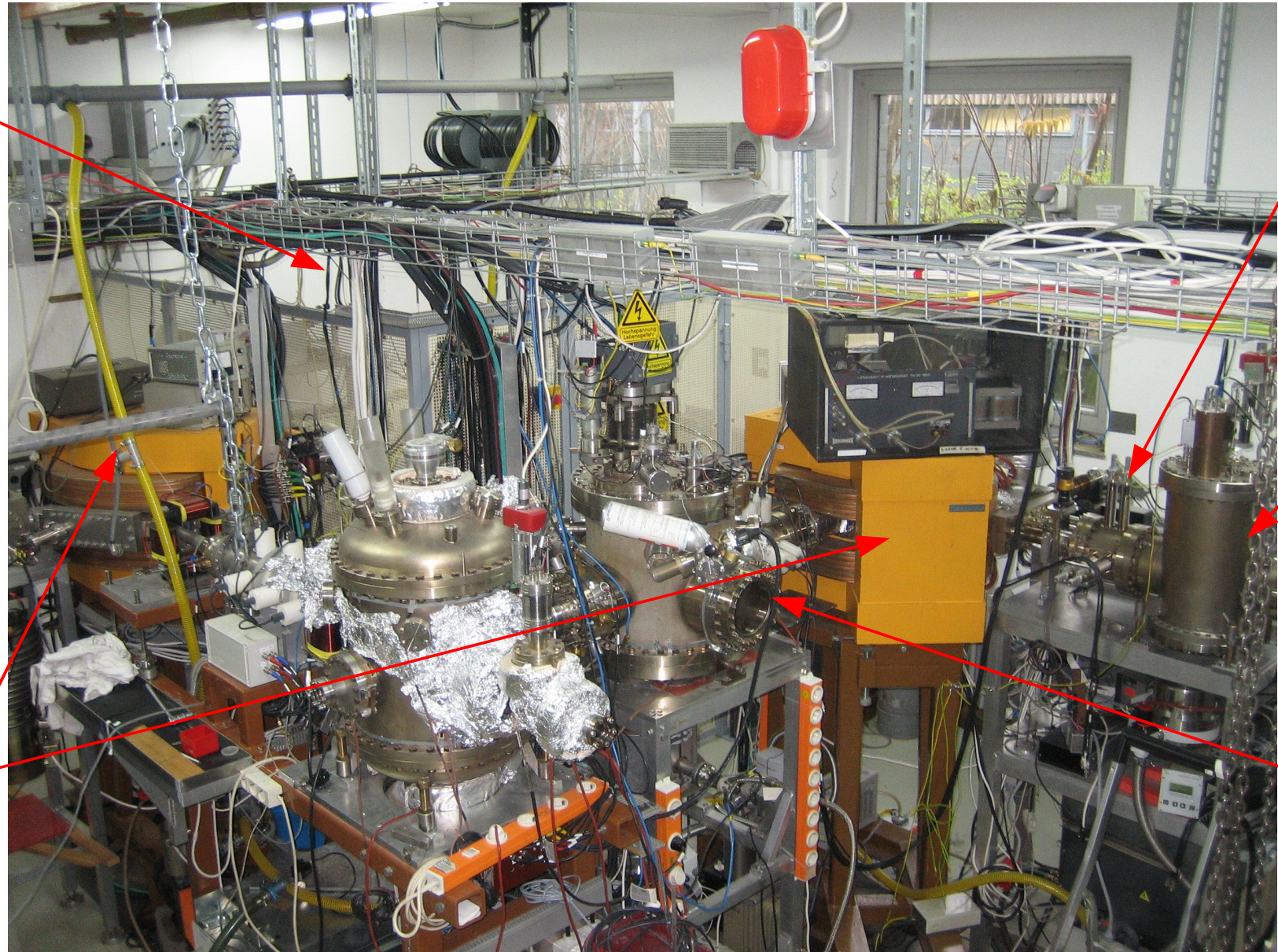
Giessen Low-Energy Single-Pass Setup

Ion source in HV-cage

Movable Faraday-Cups

Single-particle detector chamber

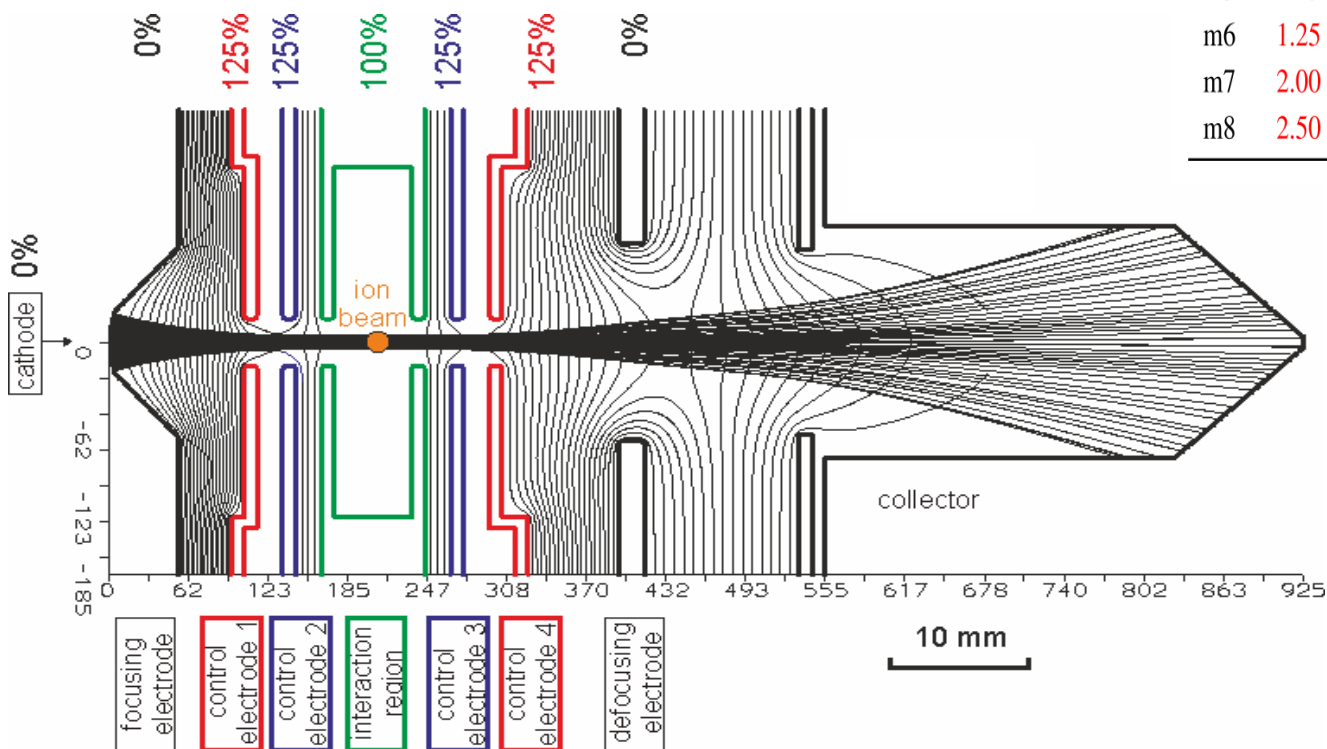
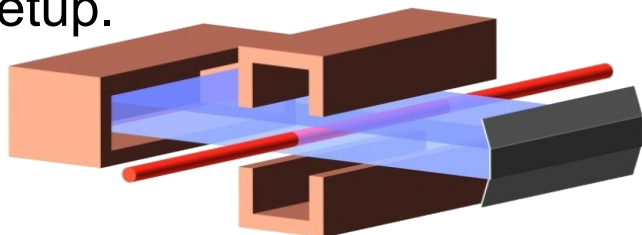
Scattering chamber with electron target



Two analyzing magnets

Electron Target at Giessen

Note: The numbers are optimized for the Giessen single-pass setup.

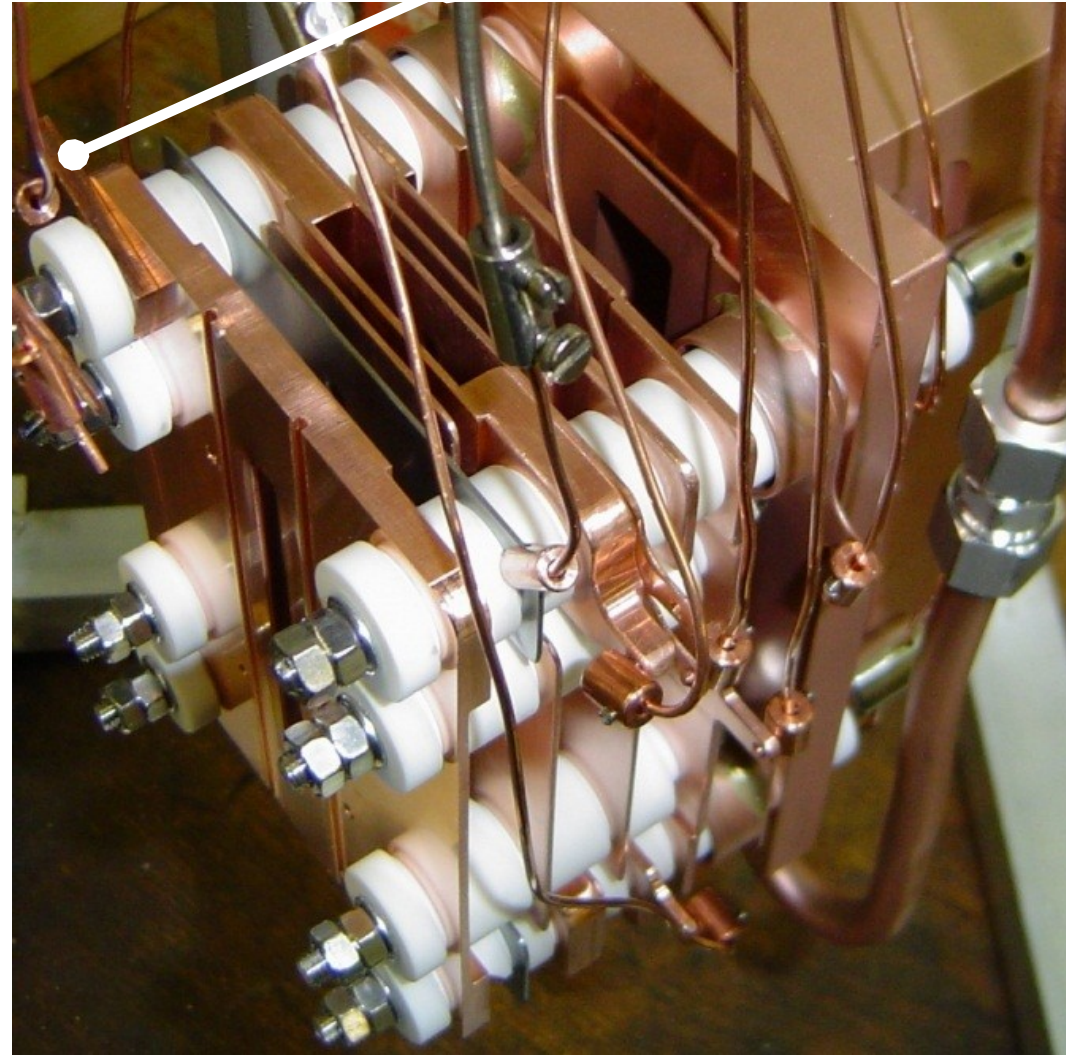


Mode	Electrode voltage ratio	Lower limit	Effect. perveance $10^{-6} AV^{-3/2}$	Trap
m1	5.00 : 1.25 : 1 : 1.25 : 5.00	$\gtrsim 10$ eV	31.1	Yes
m2	4.00 : 1.25 : 1 : 1.25 : 4.00	$\gtrsim 30$ eV	22.3	Yes
m3	3.00 : 1.25 : 1 : 1.25 : 3.00	$\gtrsim 50$ eV	14.5	Yes
m4	2.00 : 1.25 : 1 : 1.25 : 2.00	$\gtrsim 70$ eV	7.9	Yes
m5	1.25 : 1.25 : 1 : 1.25 : 1.25	$\gtrsim 100$ eV	3.9	Yes
m6	1.25 : 0.85 : 1 : 0.85 : 1.25	$\gtrsim 100$ eV	3.9	No
m7	2.00 : 0.65 : 1 : 0.65 : 2.00	$\gtrsim 100$ eV	7.9	No
m8	2.50 : 0.45 : 1 : 0.45 : 2.50	$\gtrsim 50$ eV	11.0	No

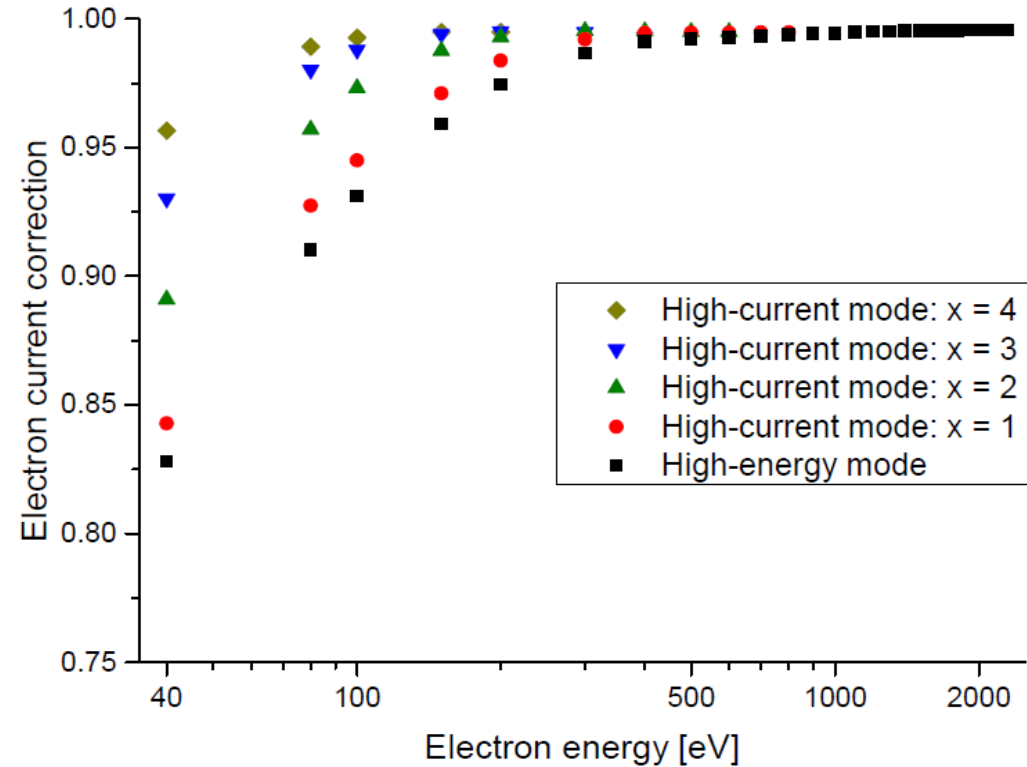
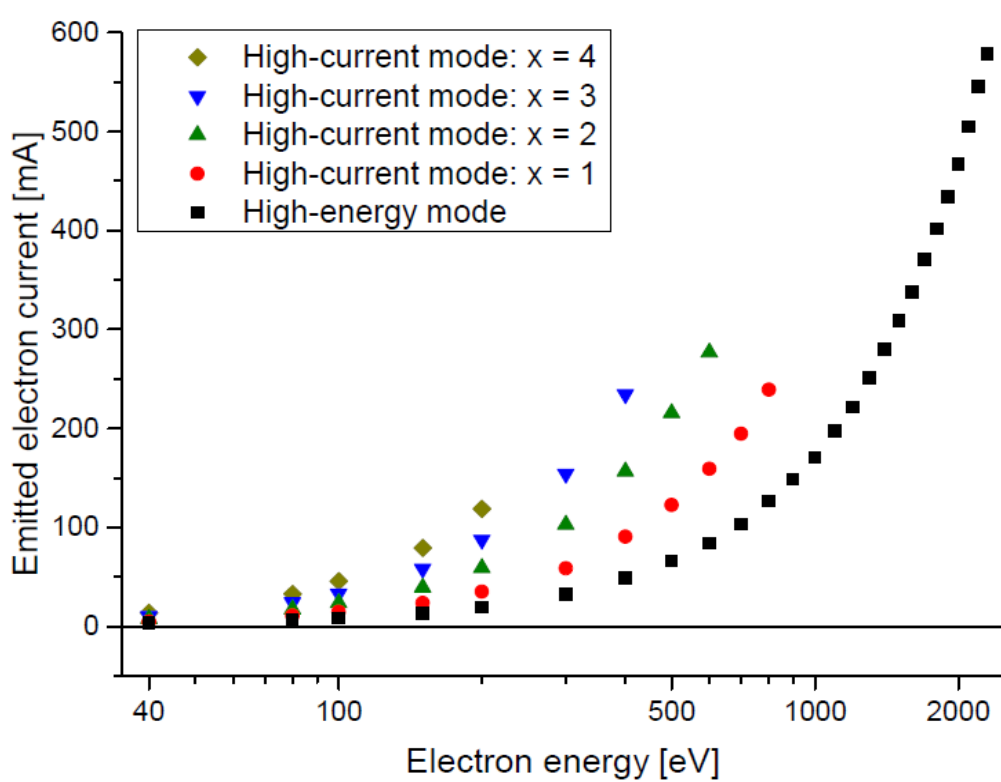
- Several modes for a flexible operation: e.g. high-current, high-energy and without a potential trap

- Successful operation of measurement principles at the Giessen single-pass setup since the 1980's

Electron Target at Giessen

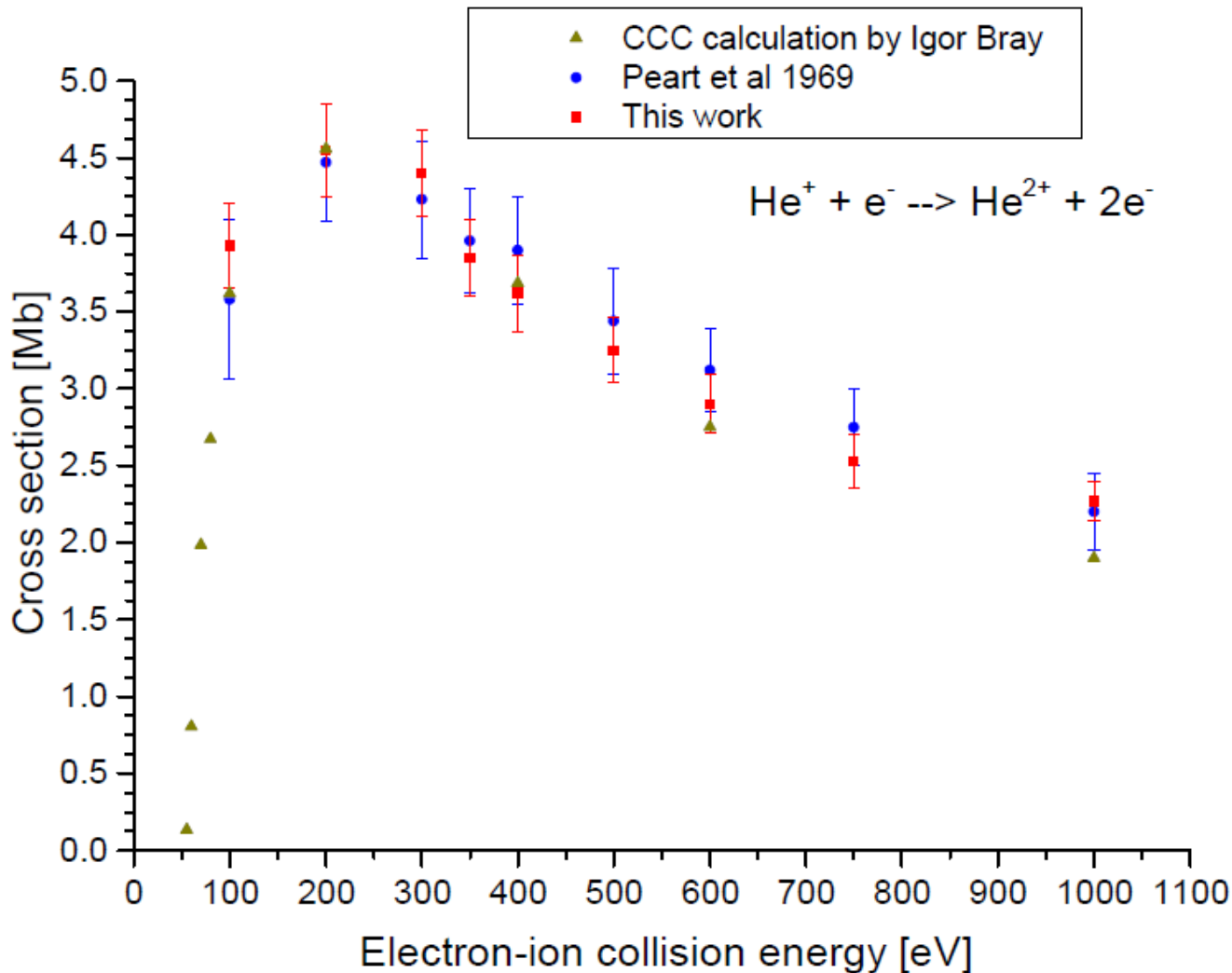


Tests at Giessen Single-Pass Setup



- Different modes do work as expected

Tests at Giessen Single-Pass Setup



- Excellent match to literature values
- For higher energies: field correction electrodes needed
→ Under testing

Outline

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Optimized for the Giessen Low-Energy Single-Pass Setup
- **Status and Outlook**

Status

- Tasks towards a dedicated transversal target for CRYRING (ongoing work):
 - Improvement of the UHV capability (goal: few 10^{-11} mbar)
 - Improvement of the high-voltage resistance
 - Larger aperture for ion beam
 - Improved collector design
 - Free view to interaction region (for spectroscopy)
 - New electron optics calculations optimized for CRYRING
 - Storage ring integration (vacuum layout and mechanical design drafted)
 - Development of a new control and data acquisition system
 - Working on integration into CRYRING/FAIR system

Calculations

- Electron energy can be varied over a wide range (by a factor of 3) by changing just one parameter and still obtaining an acceptable beam quality

→ Well behaving electron beam, non-problematic handling

- Typically synchronous changing of voltages on all electrodes

Settings:

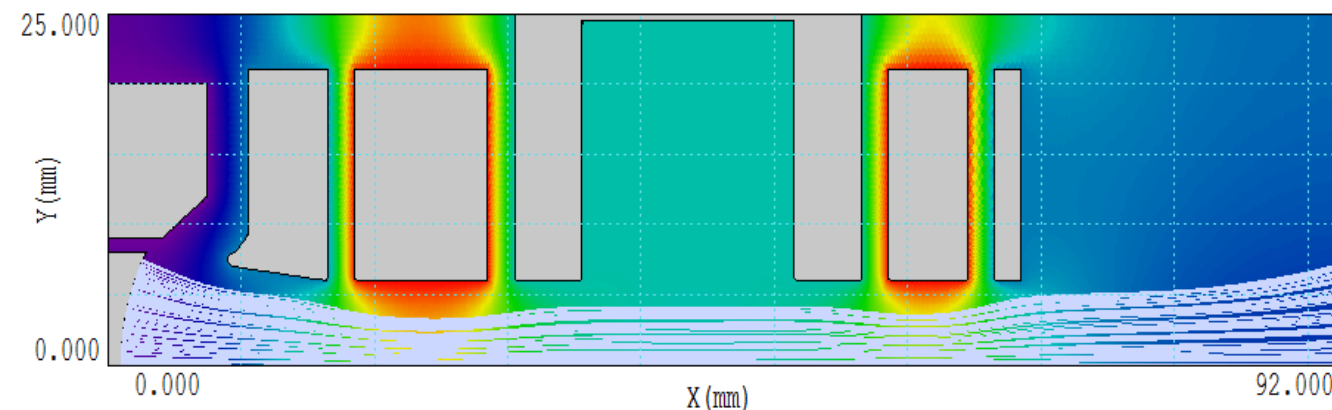
Cathode: 0 V



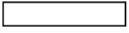
Wehnelt: -80 V

Int. region: 1200 V

1st Electrode: 900 V

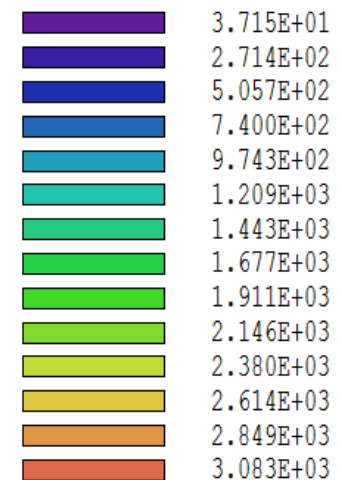
2nd Electrode: 3200 V



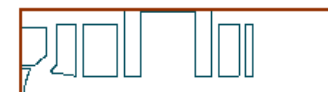
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 NSkip: 1
 Horiz. grid: 10.000
 Vert. grid: 5.000
 Filter 1: 
 Filter 2: 
 Filter 3: 

File: SHI_WIDEGAPP.EOU
 Plot type: Element
 Quantity: Phi

Minimum: -8.000E+01
 Maximum: 3.200E+03



Electron density of several 10^8 cm^{-3}



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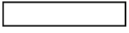
Cathode: 0 V

Wehnelt: -80 V

Int. region: 400 V

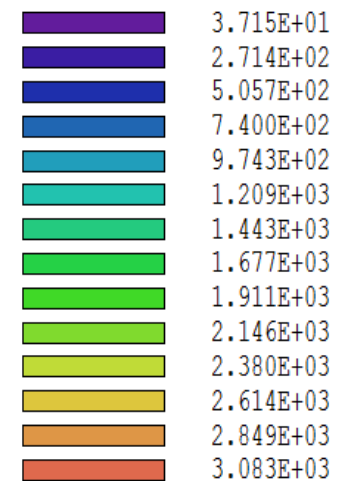
1st Electrode: 900 V

2nd Electrode: 3200 V

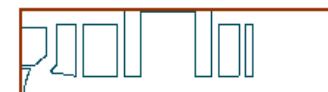
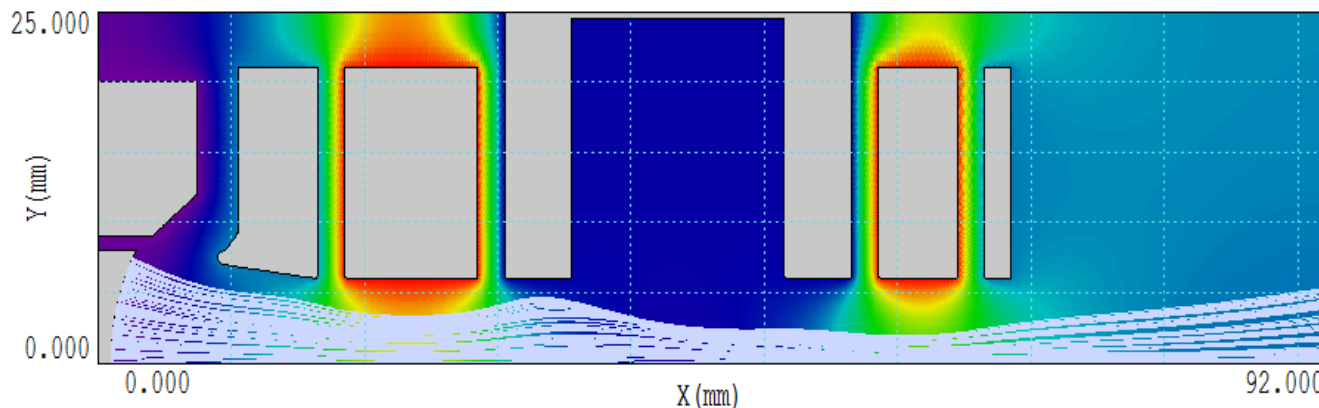
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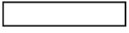
Cathode: 0 V

Wehnelt: -80 V

Int. Region: 3200 V

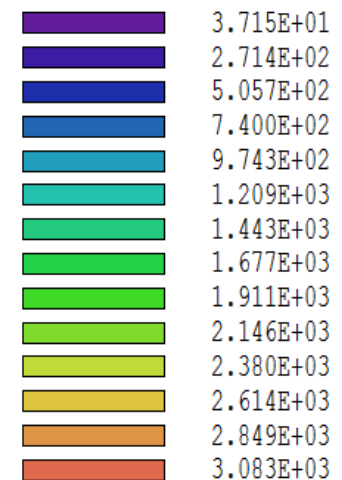
1st Electrode: 900 V

2nd Electrode: 3200 V

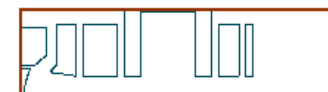
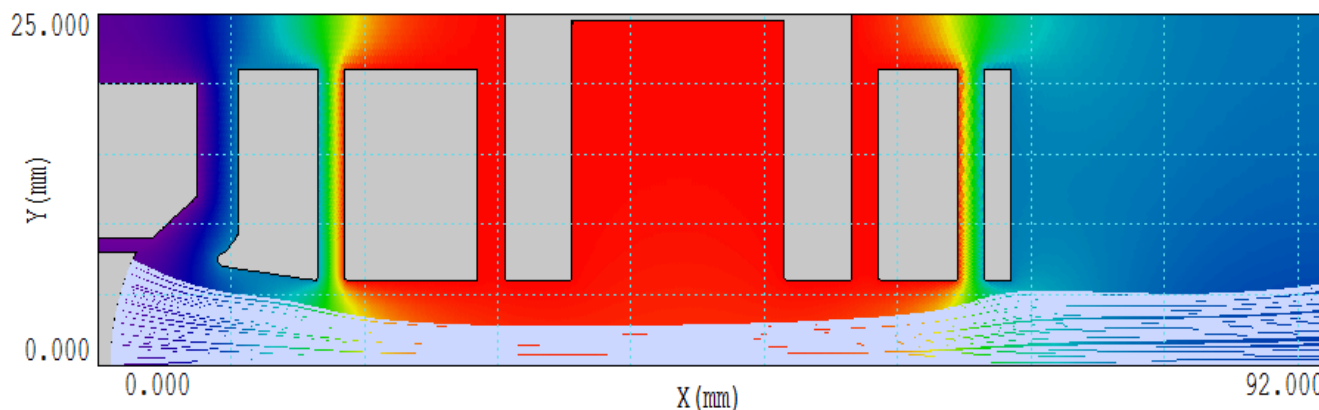
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 Plot type: Element
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Minimum: -8.000E+01
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Electron density of several 10^8 cm^{-3}



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Settings:



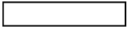
Cathode: 0 V

Wehnelt: -80 V

Int. region: 4000 V

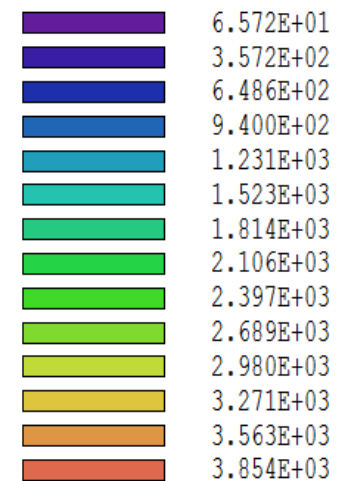
1st Electrode: 900 V

2nd Electrode: 3200 V

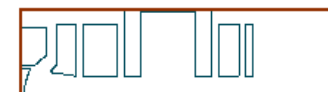
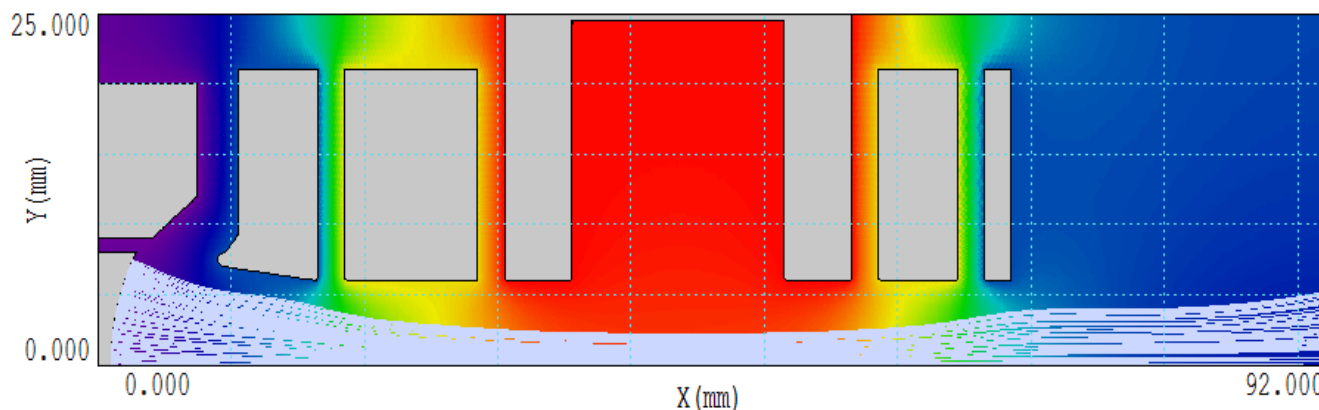
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File: SHI_WIDEGAPP.EOU
 Plot type: Element
 Quantity: Phi

Minimum: -8.000E+01
 Maximum: 4.000E+03



Electron density of several 10^8 cm^{-3}

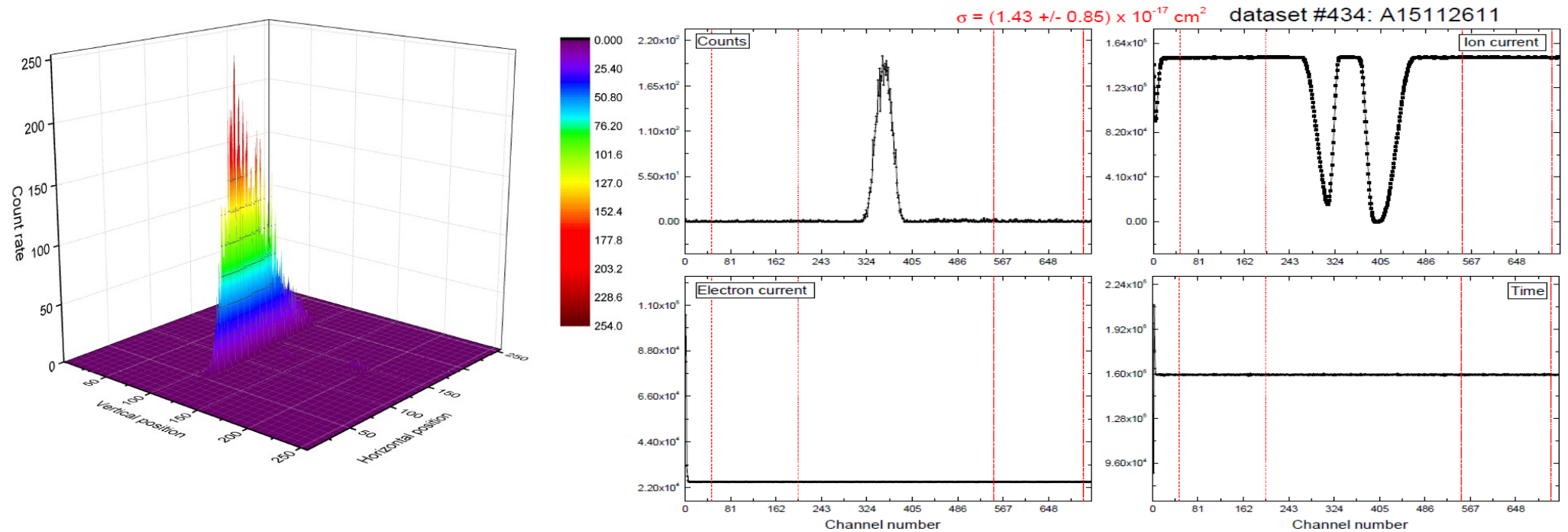


Summary

- A transversal free-electron target dedicated for experiments at CRYRING is being developed
- Enables the investigation of a long list of electron-ion collision phenomena that were not accessible until now → see CRYRING Physics Book (in print) or Instrumentation TDR (http://www.fair-center.eu/fileadmin/fair/publications_exp/TDR_CRYRING_Experimental_Instrumentation.pdf)
- Test measurements with the Giessen electron target yield valuable information for the optimization of the CRYRING target
- Work on optimizations and modifications for the CRYRING target is in progress

**Thank you for your
attention!**

Tests at Giessen Single-Pass Setup

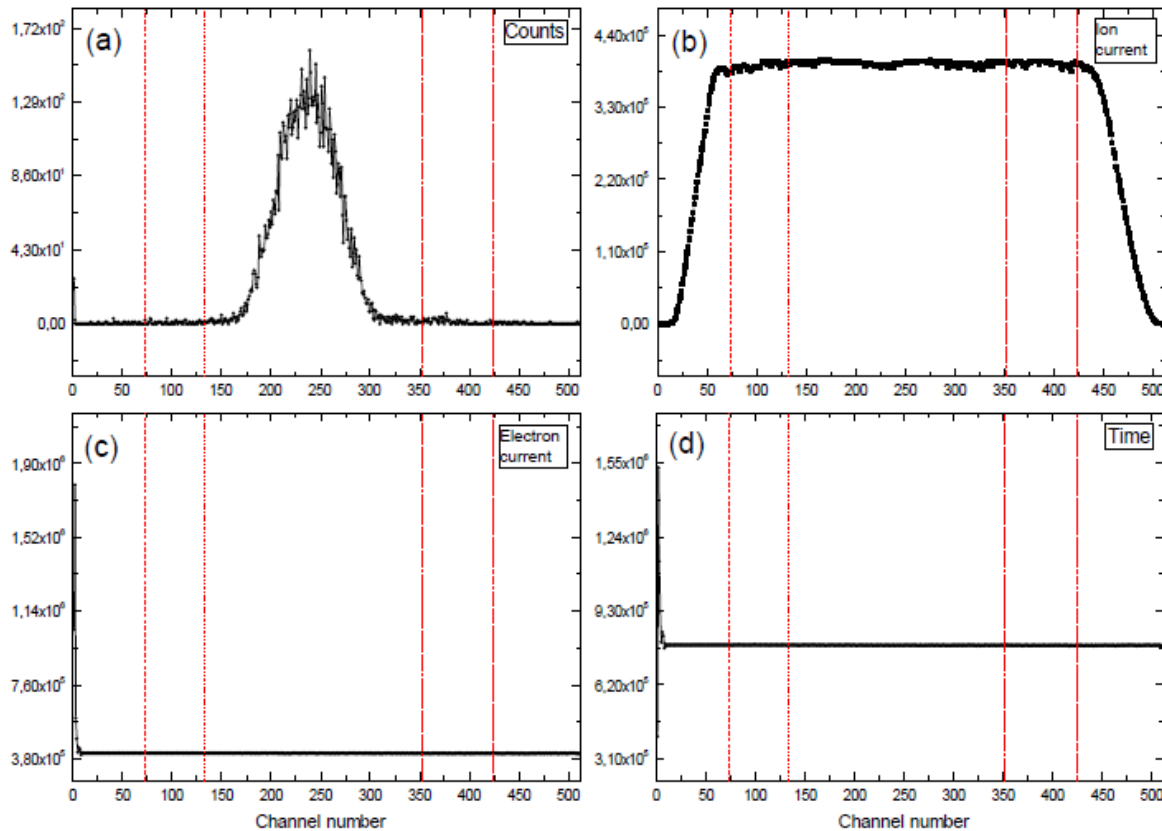


- Ion beam is influenced (deflected, splitted up) by electric field → Appropriate voltage settings on electrodes and field correction electrodes

Experimental Setup: Methods of Measurement

- Absolute measurements:
 - Deliver absolute ionization cross sections
 - To accurately know the quantity of the cross section
 - By sweeping the electron beam mechanically through the ion beam (animated crossed-beams)
- Relative measurements:
 - Deliver only relative cross section values
 - To accurately know the qualitative behavior of the cross section
 - By scanning the electron energy in very fine steps (fixed beam positions)
 - Can be fitted to absolute measurements

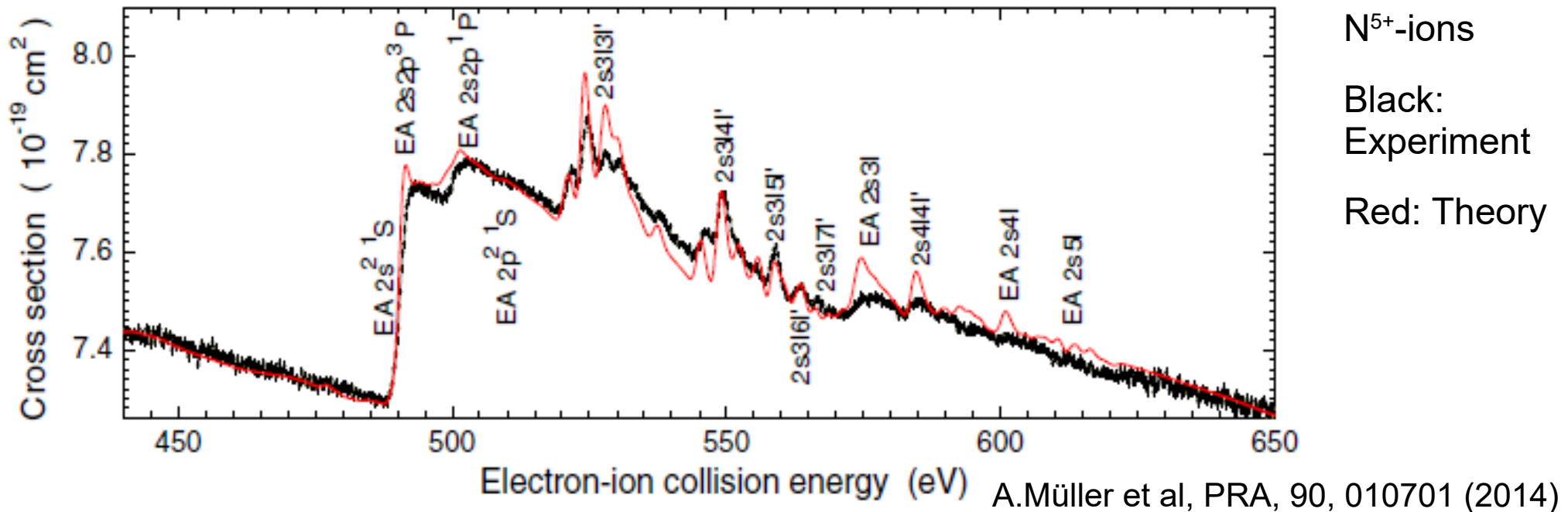
Exp. Setup: Absolute Measurements



- Systematic uncertainty can be brought down to about 6 %
- Typically steps of several up to 50 eV → No structures can be observed

- Not a trivial task at all
- Animated-beams make it a lot easier → Overlap and profile of beams get measured simultaneously with signal
- Still need to measure electron and ion current accurately as well as detect all product ions → Counting efficiency of detector

Exp. Setup: Scan Measurements



- Fine-steps of typically ~ 0.2 eV
- Ion and electron beam are fixed to the maximum overlap the entire time
- Low statistic uncertainty can be achieved in a short time as measurement is operated automatically
- Ionization threshold as well as positions of EA-thresholds and REDA/READI-processes can be determined